



R3A-28 Various Approaches for Charge Collection Efficiency Determination via Hecht Relation on CdTe/CdZnTe Detectors

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Introduction and Theory

High resistivity CdTe and CdZnTe semiconductors are very promising materials for room temperature X-ray and gamma-ray detectors with high charge collection efficiency (CCE) and mobility-lifetime ($\mu\tau$) product [1]. The higher CCE and $\mu\tau$ parameters detector has the more usable material it is. One of the most widespread method for determination of $\mu\tau$ parameter is from collected charge-voltage dependency via single carrier Hecht equation [2]:

$$CCE = \frac{\mu\tau V}{L^2} \left(1 - \exp\left(-\frac{L^2}{\mu\tau V}\right) \right) \quad (H)$$

which can be set by alpha particle collected charge-voltage dependency. But high energy particles generate enormous amount of electron-hole pairs which leads to plasma effect – inner screening of internal field at the location of a particles absorption [3]. Due to this effect modified Hecht equation can be used [4]:

$$CCE = \frac{\mu\tau(V+V_i)}{L^2} \left(1 - \exp\left(-\frac{L^2}{\mu\tau(V+V_i)}\right) \right) \quad (MH).$$

The other modification can be set due to surface recombination velocity:

$$CCE = \frac{1}{1 + \frac{s}{\mu(V+\varepsilon_s)}} \frac{\mu\tau V}{L} \left(1 - \exp\left(-\frac{L^2}{\mu\tau V}\right) \right) \quad (SH),$$

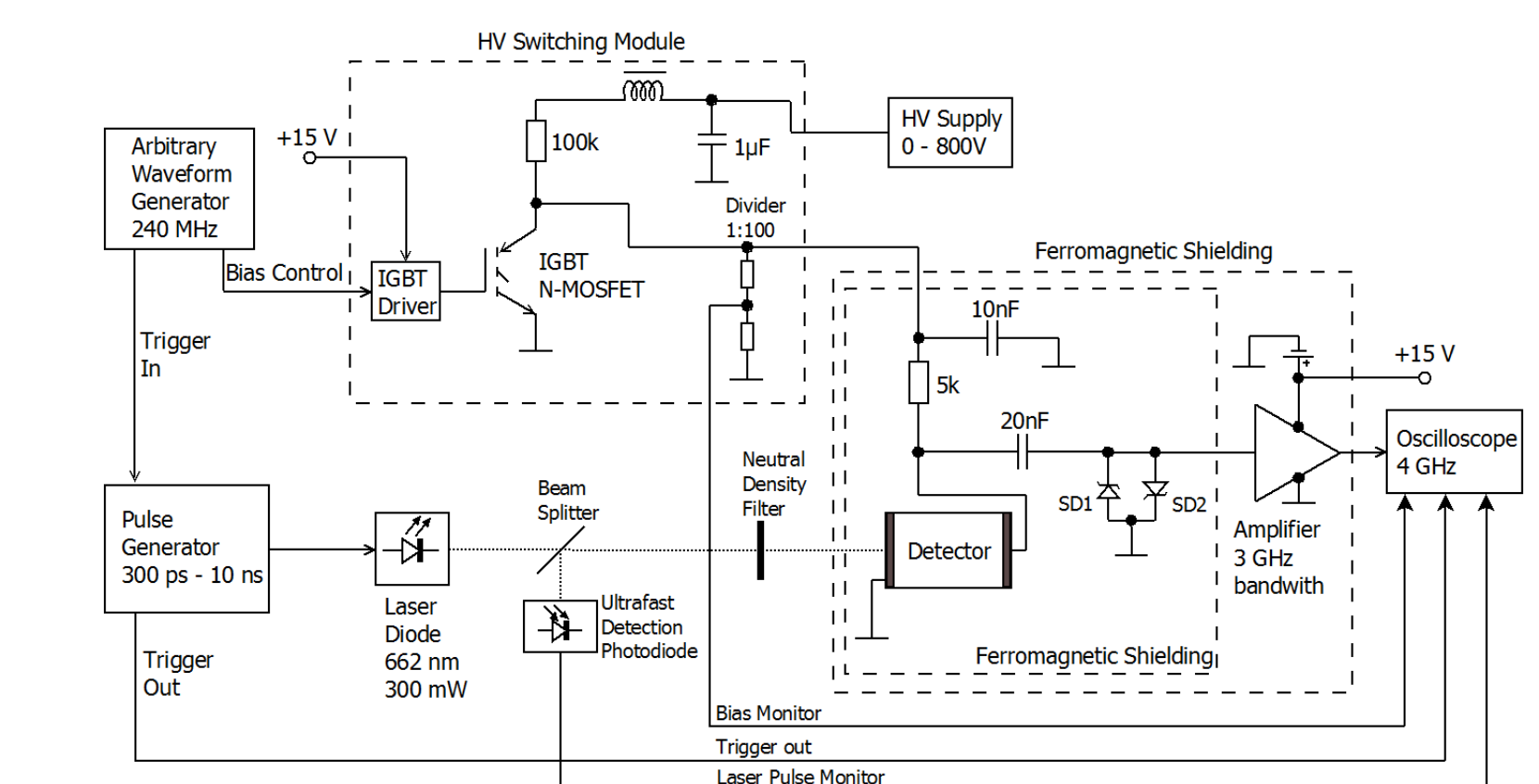
(ε_s – characteristic contribution of band banding to a mean field at the surface)

Experiment

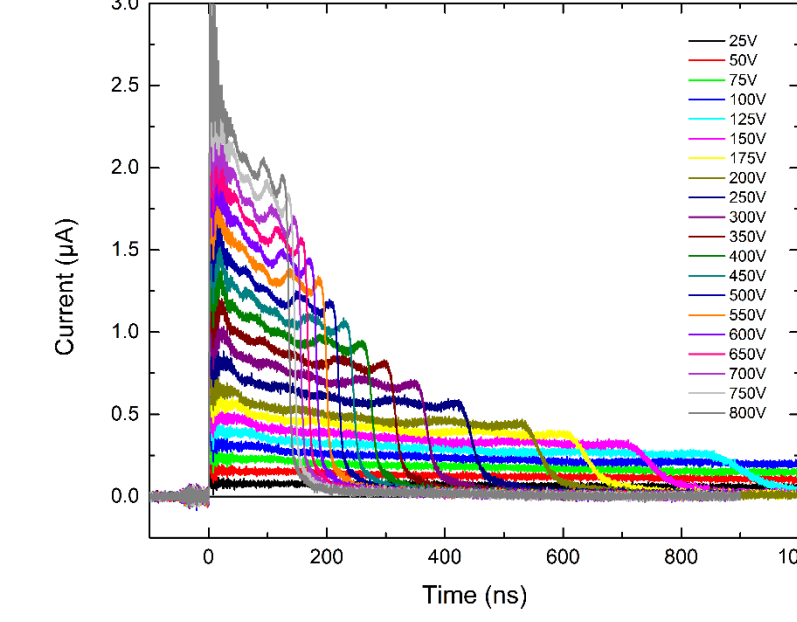
Five methods have been used to set collected charge-voltage dependency:

1. $^{241}\text{Am } \alpha$ (5,5 MeV) particle pulse height spectrum analysis (Alpha) [4]
2. $^{241}\text{Am } \gamma$ (59,6 keV) and RTG (17,6 keV) pulse height spectrum analysis (Gamma), (RTG)
3. Laser (660 nm) pulse height spectrum analysis (L-TChT)
4. Laser (660 nm) Transient Current Technique (L-TCT) [3]

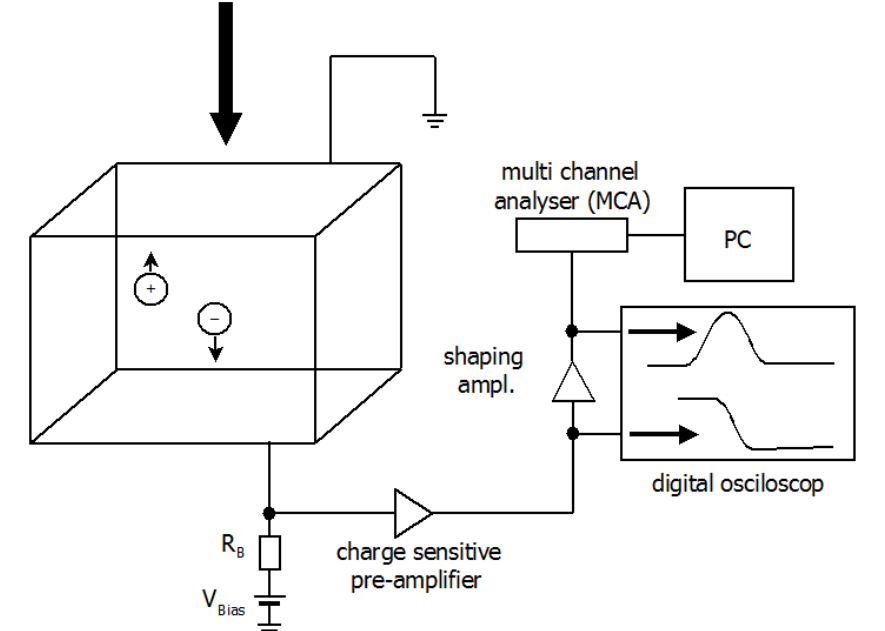
Transient Current Technique (TCT)



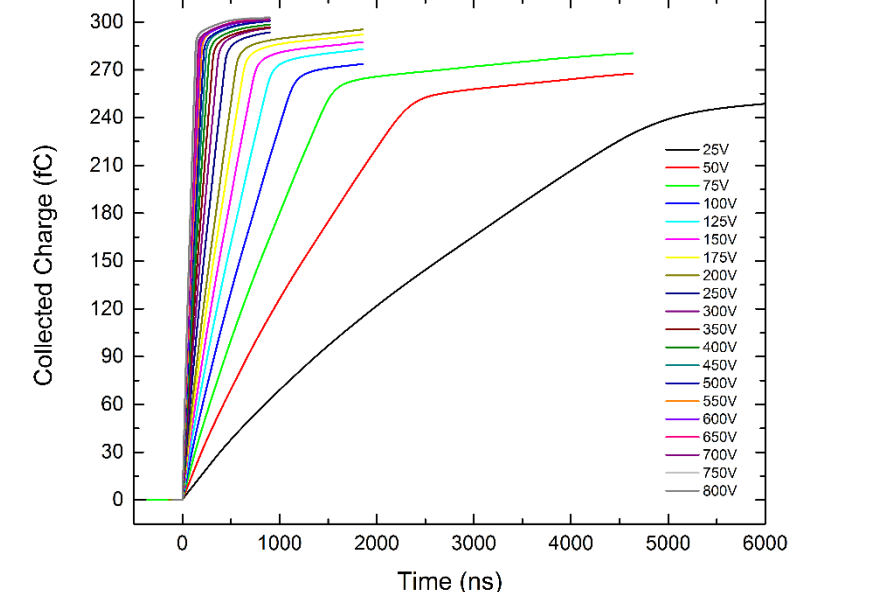
Obtained TCT waveforms



Pulse High Spectrum Analysis



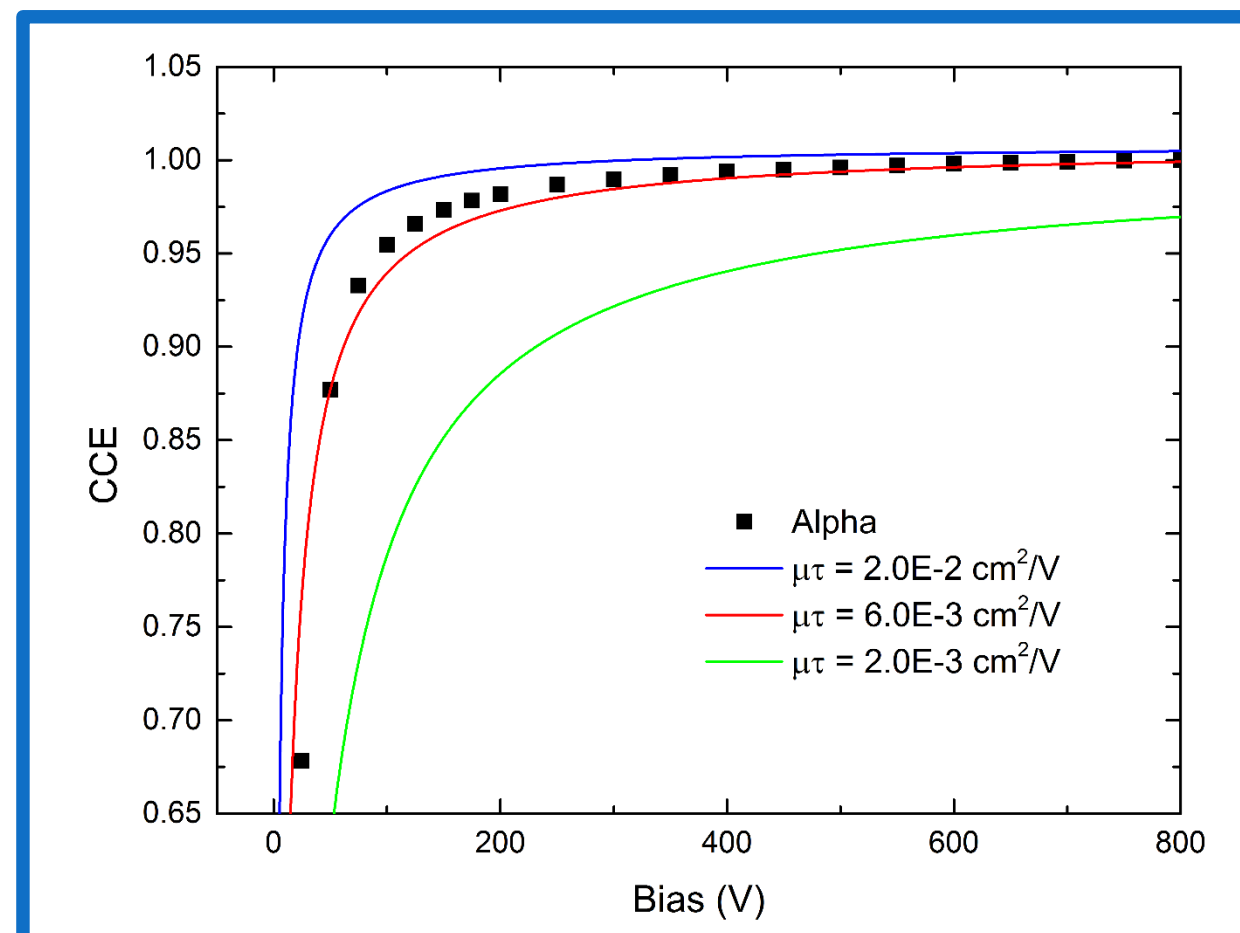
Counted Charges



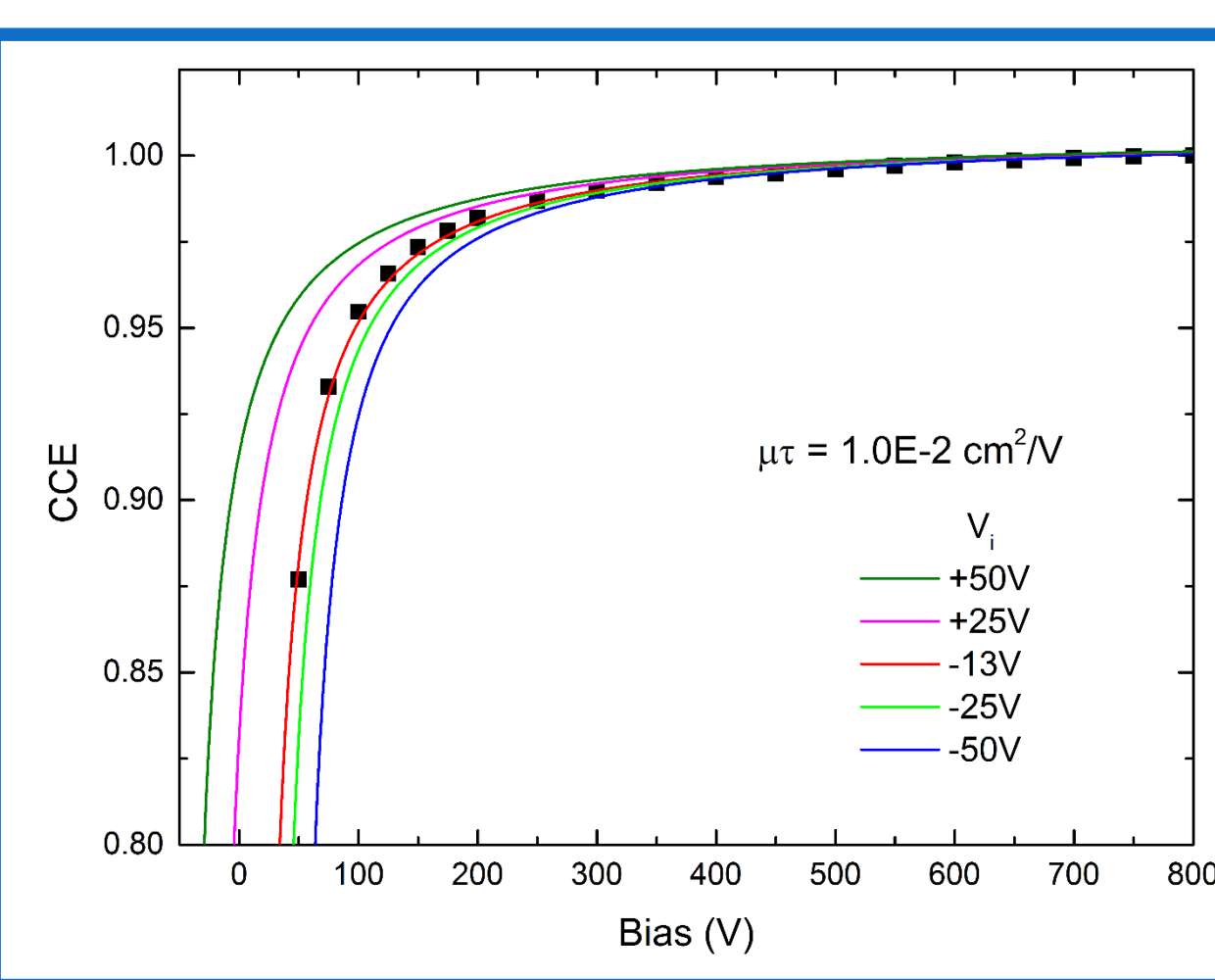
Results and Discussion

Influence of fitting parameters for obtained Alpha particle data of CdZnTe sample (common parameter $L = 3,15$ mm).

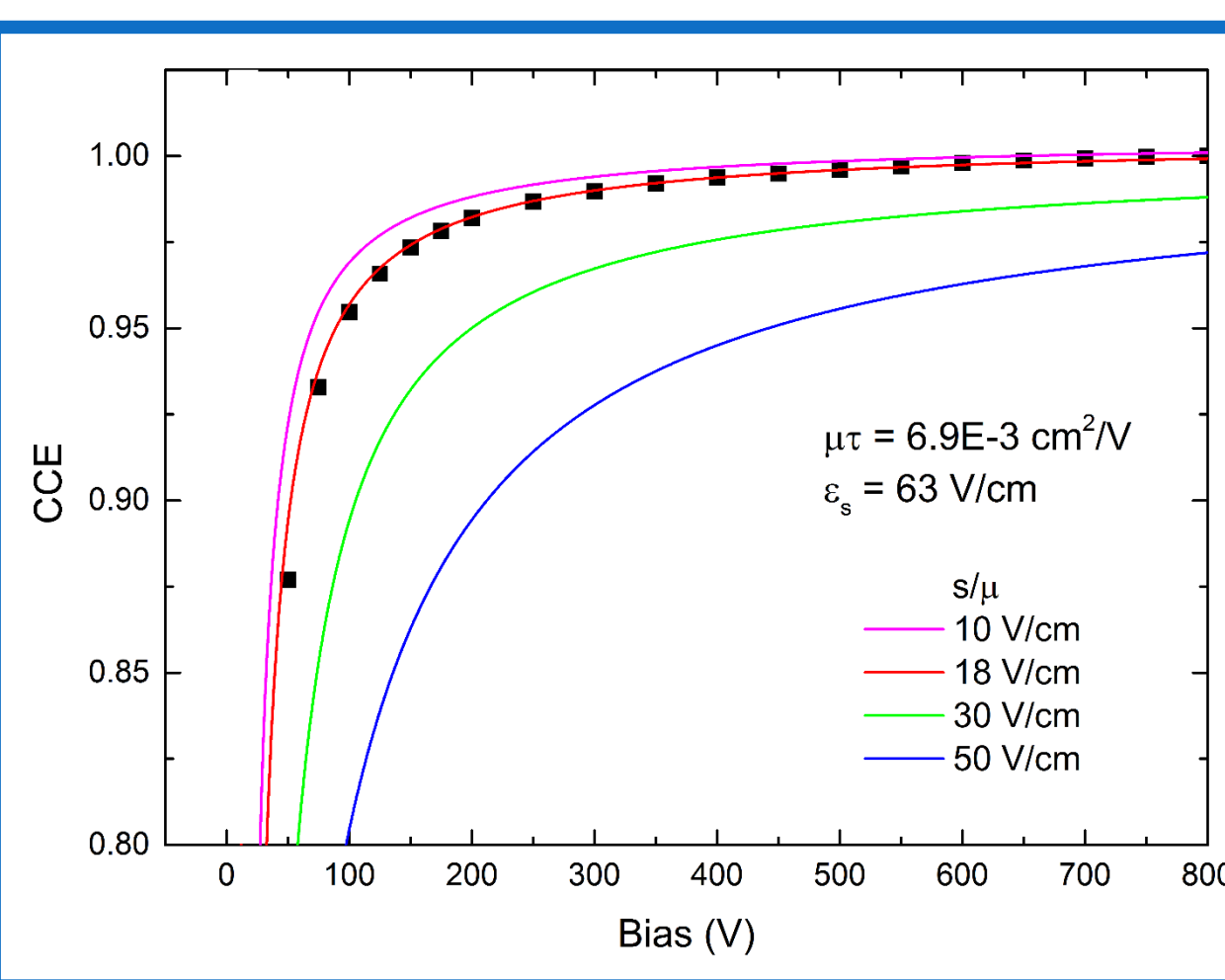
Single carrier Hecht equation (H). Influence of different values of $\mu\tau$ parameter.



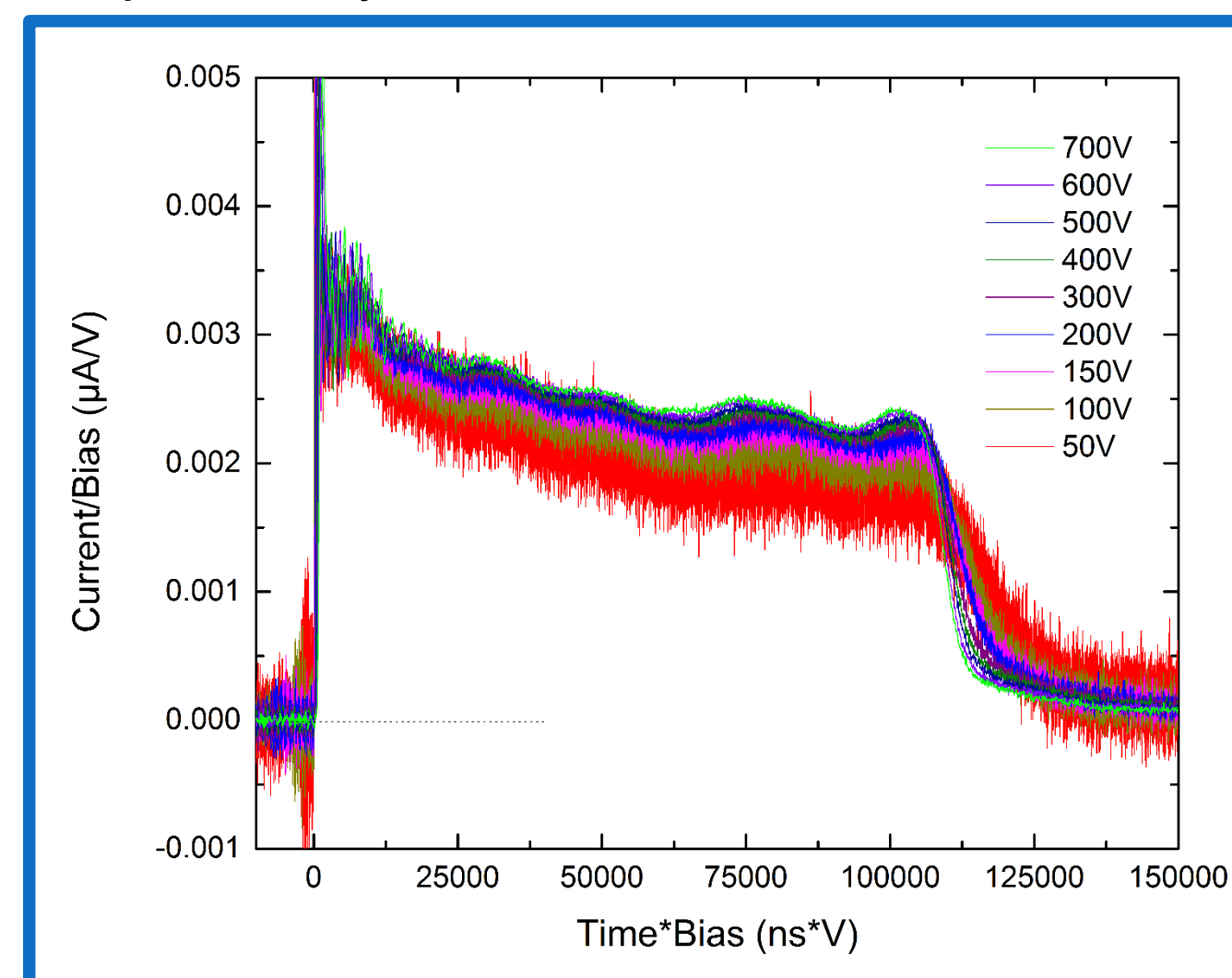
Modified Hecht equation (MH). Influence of different V_i produced by polarization field within the device.



Surface Hecht equation (SH). Influence of different surface recombination velocity s.

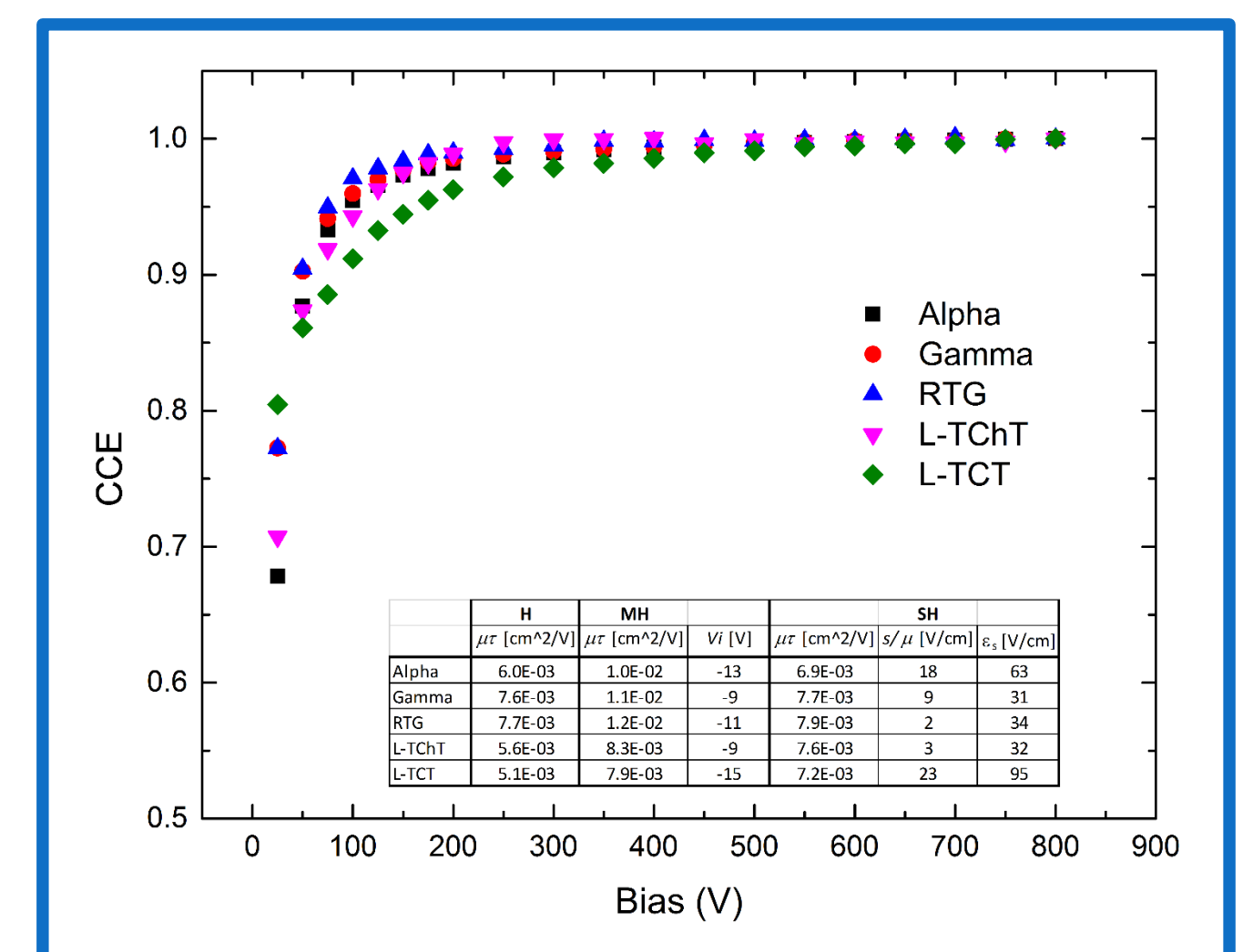


Normalized TCT waveforms of CdZnTe sample. Similar curves indicates a rapid saturation in collected charge-voltage dependency.

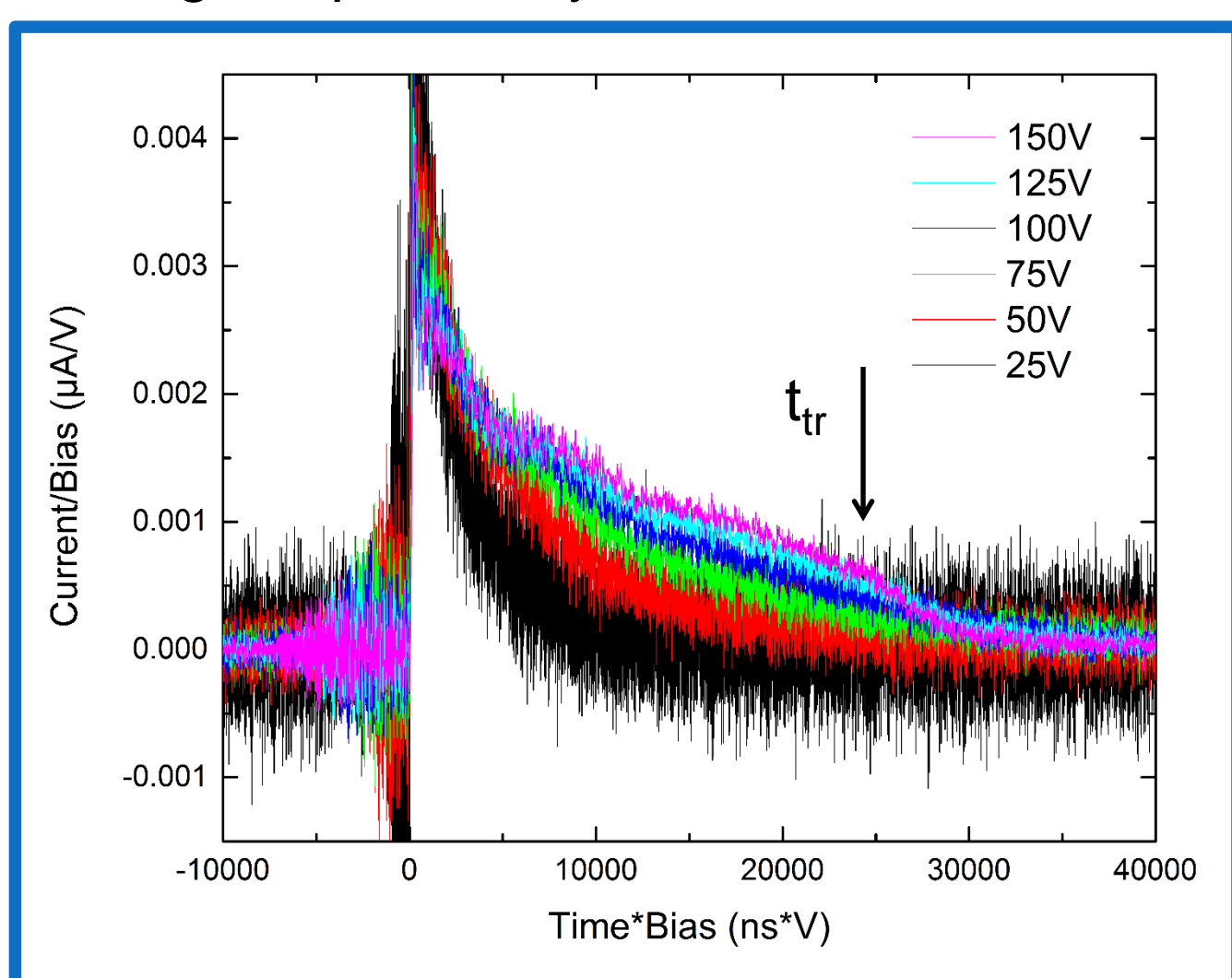


CdZnTe
 $L = 3,15$ mm

Collected charge-voltage dependency of CdZnTe sample. High V_i in (MH) indicates wrong values of $\mu\tau$. We obtained good match in (CH) and (SH) for small surface recombination.

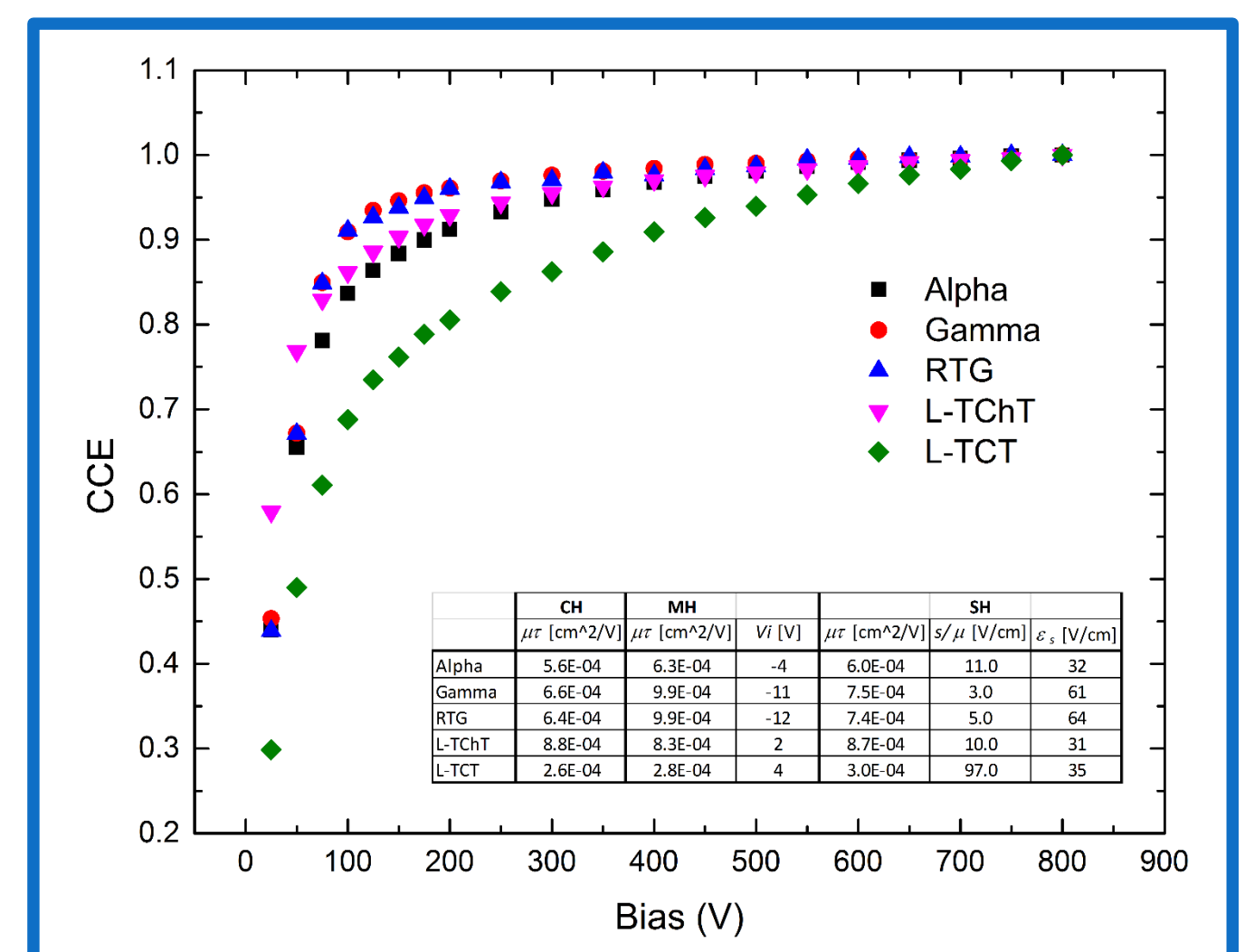


Normalized TCT waveforms of CdTe:In sample. Low voltages show the absence of transit time, thus we have inactive layer under the anode = low values in collected charge-voltage dependency for those biases.

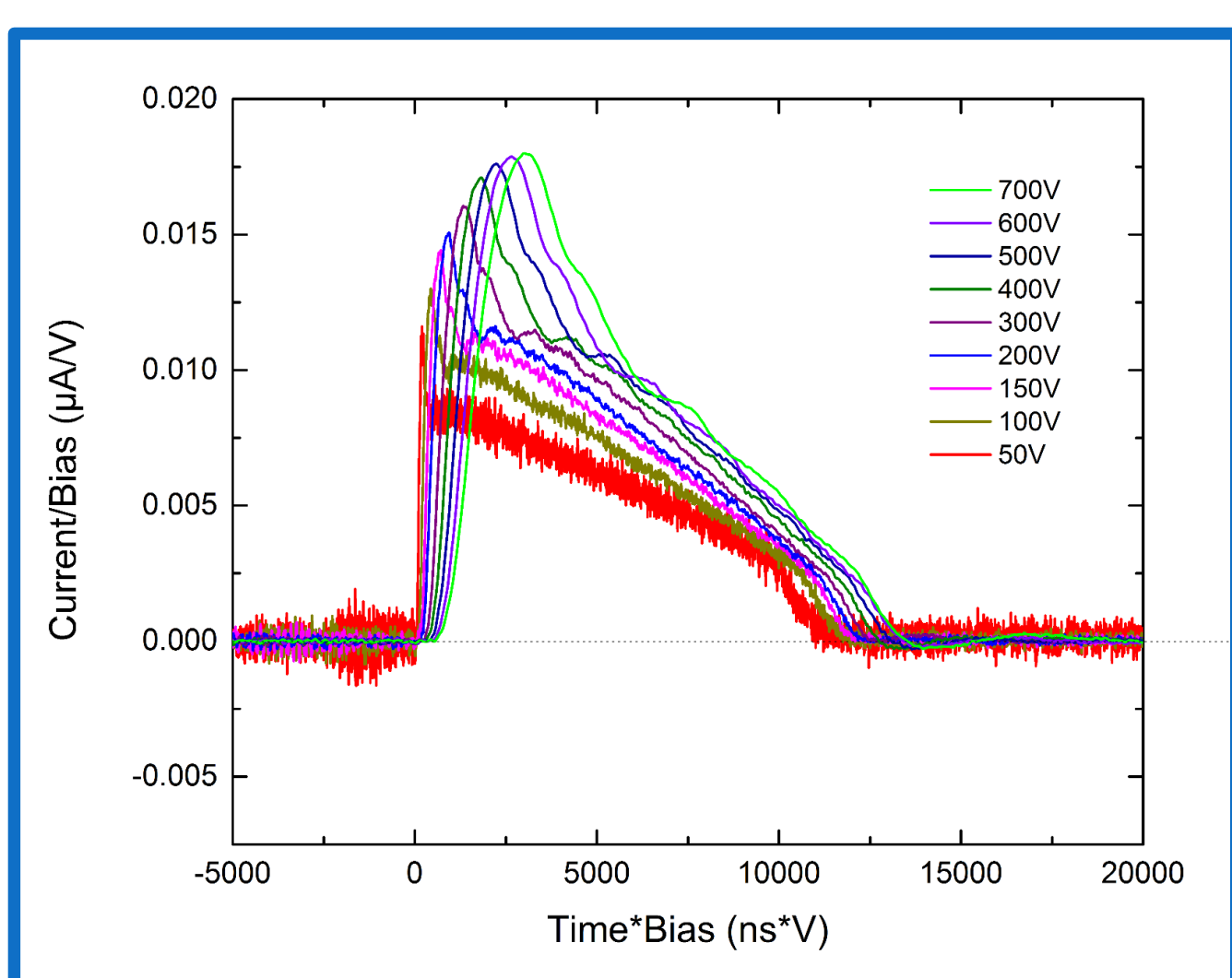


CdTe:In
 $L = 1,65$ mm

Collected charge-voltage dependency of CdTe:In sample. Low obtained values are distorted by inactive layer.

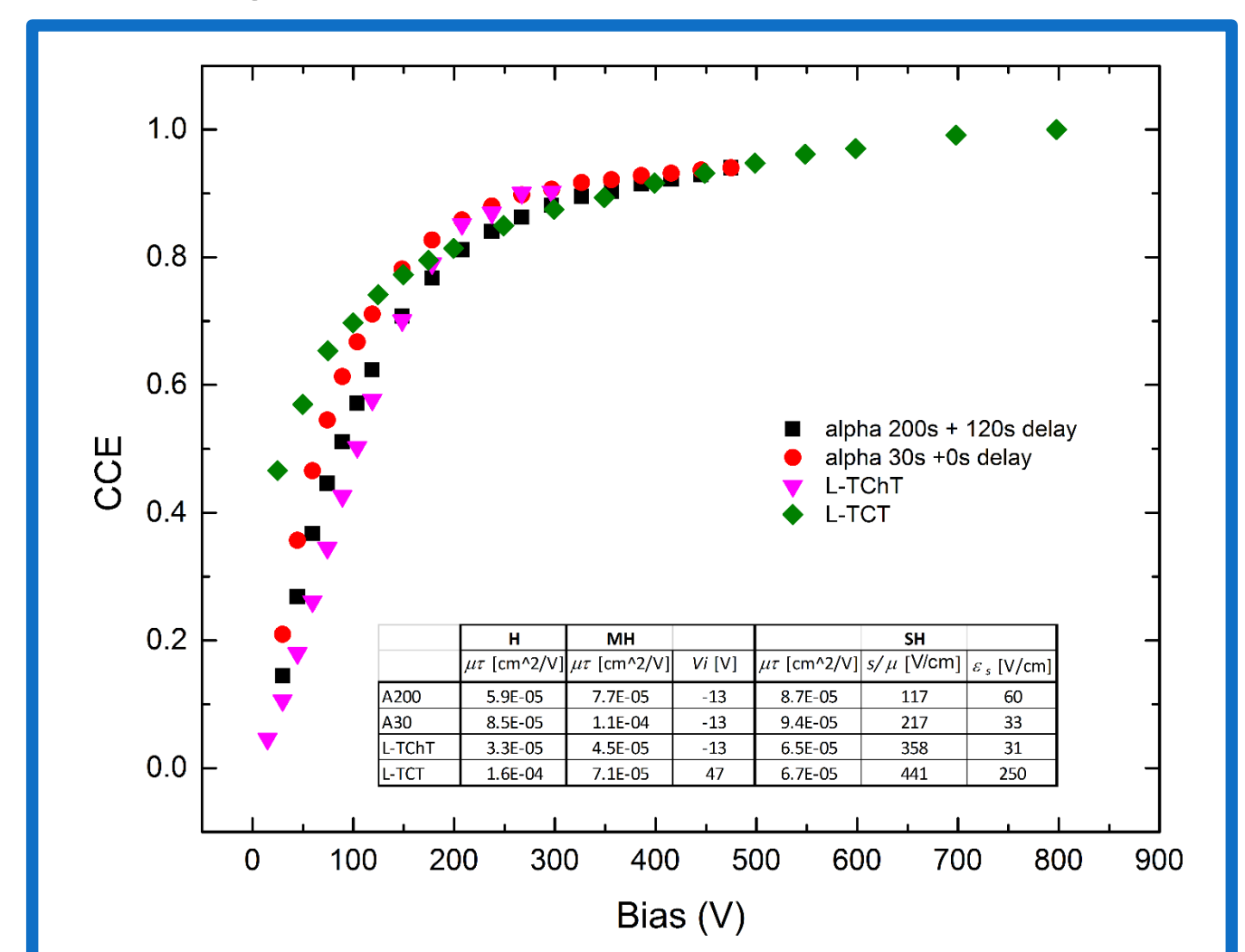


Normalized TCT waveforms of CdTe:Cl sample. The increasing character correspond to a large surface recombination.



CdTe:Cl
 $L = 1$ mm

Collected charge-voltage dependency of CdTe:Cl sample. Due to a similar resistance of the sample as the value of R_B , it is not possible to measure spectral analysis to higher voltages.



Conclusion

- ➔ Modified surface recombination Hecht equation (SH) gives good values of $\mu\tau$ parameter, if we counted the influence of characteristic contribution of band banding to a mean field at the surface – ε_s .
- ➔ It is always good to complete spectral analysis with TCT measurements, because the samples with inactive layer under the low voltages distorts the obtained values of $\mu\tau$ parameter due to this effect.
- ➔ Normalized TCT waveforms show the influence of surface recombination.
- ➔ Simple modification of Hecht equation (MH) is not sufficient and the high values of V_i do not correspond the real state.

References

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- [4] M.C. Veale, et Al., Nucl. Instr. Meth. Phys. Res A, **579**, 90-94 (2007)

Acknowledgement

1. Grant agency of the Czech Republic under Grant no. GACR P-102-15-05259S
2. Grant agency of Charles University, Grant no. 1054213/2015 and Grant no. 2052214/2015
3. Grant SVV-2015-260216